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PATENT

Docket No.: 50432-067

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Kai YANG, et al.

Serial No.:

Group Art Unit:

Filed: March 27, 2001

Examiner:

For:

STABILIZING FLUORINE ETCHING OF LOW-K MATERIALS

## PRELIMINARY AMENDMENT

Commissioner for Patents Washington, DC 20231

Sir:

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Prior to examination of the above-referenced application, please amend the application as

follows:

IN THE TYLE:

Please change the title from "DAMASCENE PROCESSING USING DIELECTRIC

BARRIER FILMS" to -- STABILIZING FLUORINE ETCHING OF LOW-K MATERIALS--.

REMARKS

Entry of this preliminary amendment is respectfully requested.

Respectfully submitted,

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**Date: March 27, 2001** Facsimile: (202) 756-8087